

**ABSTRACT**

A method of fabricating a liquid crystal display includes forming a gate insulating film to have different thickness in accordance with position. A liquid crystal display according to an embodiment of the present invention comprises a first thin film transistor formed in a picture display part together with liquid crystal cells each provided at each crossing area of a plurality of signal lines for driving each of the liquid crystal cells; a second thin film transistor included in a drive circuit that generates a drive signal to drive the signal lines and formed in a drive circuit part located at the outer area of the picture display part; and a gate insulating film formed between an active layer and each gate electrode included in each of the first and second thin film transistors, and having a structure of at least two-layers, inclusive of an etch-stopper layer, and wherein the gate insulating films of the first and second thin film transistors are formed to have different thickness from each other.